



# **MX61/MX61L/MX51**





# The best way to the best results





The highest efficiency...for all our



Olympus' key priority is the needs of each individual customer.

Naturally, we aim to ensure that our inspection microscopes deliver maximum benefit from the time of selection right through to after-sales support. And with our long experience of the industry, we already provide many clear-cut solutions to making electronic device inspections easier, quicker and more efficient.

At the same time, we know that each customer is unique, and has to address a unique set of issues to successfully incorporate the microscope into the production process. That's why we are always ready to help, at an individual, local level, providing ideas, solutions and support tailored to specific application needs.

The highest efficiency for all our customers — that's the commitment underlying the launch of our new MX61/MX61L/MX51.

### customers





Olympus MX microscopes benefit every customer right from the start — meeting their needs in full, without wasting time or money.



## Front-mounted main controls for faster, more efficient operations.

The adjustment of AS (Aperture Stop) open/close, which plays a key role in determining image contrast, is synchronized with objective exchange and observation method, and controlled by buttons. Inspection efficiency is further improved by the front-panel location of the light adjustment, which can be operated by a single finger. The buttons for objective exchange and AS are positioned crosswise for easy operation with the thumb only, so that the user

does not have to let go of the focusing handle. The crosswise button layout also enhances fingertip sensitivity and prevents operating mistakes.

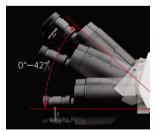


Reflected light adjustment dial
 Objective magnifications
 exchange buttons
 AS open/close buttons

# Tilting trinocular tubes to suit any viewing posture.

Adjusting chair height or adopting an unnatural posture to suit the operator's eyepoint are just two of the many small inconveniences that can slow down working speed. With this in mind, the MX61/61L is equipped with a tilting tube whose tilt angle can be varied from 0° to 42° (variable height: 150mm, compatible with SEMI S8); this allows operators to find their most comfortable posture, regardless of physical differences, and also enables inspection while standing. The tube also features a long distance from the center of

the observation axis to the eyepoint, so that even a large stage can be operated easily.



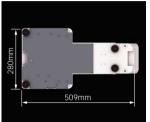
# SEMI S2/S8 compliance ensures safety and reliability.

The MX61/61L comply in full with international specifications and standards such as SEMI S2/S8, CE, and UL, and respond to environmental and safety issues with a high level of reliability.

### Clean Class 1 conformity: numerous features to exclude dust.

All driving components are housed in a shielded structure and are made of materials that offer excellent abrasion resistance and conformity with Clean Class 1. (There is a separate Class 1 compatible model for use with a revolving nosepiece.) MX61 is capable of accommodating up to 200mm wafers and MX61L up to 300mm wafers with the same small footprint. The depth of the 300mm wafer compatible system is amazingly small, occupying just 537mm on the

table, or 677mm to the end of the lamp housing.



MX61/MX61L occupy small footprint area

# Optimized construction materials with upgraded anti-static protection.

Antistatic processing is applied to the microscope frame, tube, breath shield and other

parts, to prevent wafer contamination.



Antistatic breath shield

# Safe, quick wafer handling improves product throughput.

A wafer loader can be attached to both MX61/61L models with no significant increase in overall footprint size. Safe, efficient operation, from back macro to micro inspections, can be performed without using tweezers. The wafer cassette can easily be set from the front side.



MX61 combined with AL110 wafer loader (200mm version)

Speedy detection of any flaw ensures faster, more productive throughput.

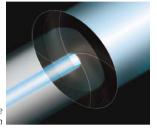


# Simultaneous AS (Aperture Stop) adjustment and objective switching obtains optimal contrast instantly, making inspections much faster.

Inspections are slowed down if AS adjustment has to be performed manually every time the objective is changed. But with the MX61/61L, users can preset AS in 14 steps for each level of objective power, ensuring optimal image contrast immediately whenever the objective power or the observation mode is changed. This eliminates the

time and effort spent on AS adjustment, reduces operator fatigue and speeds up the inspection process.

> Powered aperture diaphragm



### Easy switching and addition of observation methods.

Both MX61/MX61L microscopes offer quick selection of observation mode via a single lever — brightfield, darkfield and optional cube. A transmitted light illumination unit can also be combined with both microscope stands, to

enable the transmitted light polarizing observation required for FPD inspections.

Observation method selection



### Two high-precision stages for faster sample positioning.

Two stages are available: the MX-SIC1412R2, which complies with wafers up to 300 mm and a 17-inch panel, and the MX-SIC8R which complies with wafers up to 200mm. The former provides a larger Y transmitted light illumination area (284mm) than the previous model (increased by 55mm in the Y-axis). In addition, the stage grip has a built-in clutch, to allow exchange between fine and coarse movement while retaining the grip on the handle: this enables unrestricted stage movement while

observing through the eyepiece, and facilitates faster inspections.



Qucik operation of stage grip with built-in clutch

#### Faster objective exchange.

The motorized nosepiece revolves 20% faster than previous models, and objective exchange (low-high/high-low magnification) is button operated, enabling faster inspection speeds. Users can select from among 3 clean-type

revolving nosepieces, according to need.



### Various holders for different sizes of sample.

Users can select various types of 8"-6" and 8"-12"\* wafer-sized wafer holders, mask holders, and glass plates. As a result, the production line can be modified at minimal cost even when the object of inspection changes. With the MX61, different stages can be used to accommodate

3", 4", 5" and 6" wafers on the inspection line.
\*MX61L only



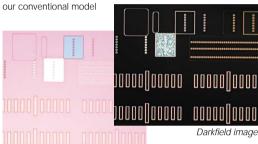
①MX-WHPR128 ②MX-SPG128 ③BH3-SPG6 ①MX-WHPR86 ⑤BH2-WHR65 ⑥BH2-WHR54 ⑦BH2-WHR43 ⑥-⑦: Need to combine with BH3-WHP6 High resolving power and high image sensitivity support faster, more accurate analysis.



### 7 times brighter darkfield images deliver a remarkable improvement in defect detection.

The newly-improved optics deliver brighter darkfield images (approx. 7 times brighter on average\*) and better darkfield observation effects, enabling quick, reliable detection of minute scratches that would previously have been overlooked. Clear, high-contrast brightfield images with optimized color temperature also capture color tone differences with outstanding precision.

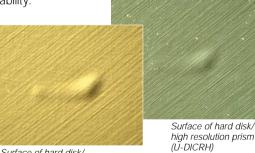
\*Combined with recommended objectives and compared with



Brightfield image

### Optimized DIC contrast for different surface conditions enhances defect detection.

Three kinds of DIC prism — standard, high contrast or high resolution — can be selected according to the surface irregularities and reflection characteristics of the samples. This delivers images with optimized contrast and spatial effect, greatly improving defect detection ability.

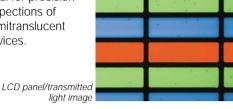


Surface of hard disk/ High contrast prism (U-DICRHC)

### Simultaneous use of reflected and transmitted light.

Reflected light and (optional) transmitted light illumination systems can be used simultaneously. with independent intensity adjustment for each.

This combination is ideal for precision inspections of semitranslucent devices.



### High N.A. and long working distance objectives improve operability.

Different types of UIS objectives that combine high resolving power with long working distances are available. These objectives minimize direct contact with samples caused by inaccurate

operation of the focusing knob, and deliver the clear, high-resolution images needed for more precise analysis.



LCD objectives\*

0.6mm in thickness). Please ask for details

#### High performance imaging systems.

Digital cameras can be attached to the various types of tubes. Olympus offers a wide range of highly cost-effective specialized models, and also provides a variety of adapters for attaching digital cameras or video cameras that the operator already owns.



A complete range of accessories, available when and if you need them — no other exclusive optical microscope required.



#### Minimizing wafer inspection time.

#### Auto focus system MX-AF

This auto focus unit for the MX61/61L is compatible with all reflected light observation methods, including darkfield and Nomarski DIC. Fast and precise, it responds instantly to changes in the observation position to provide accurate focusing in real time.





Auto focus sensor unit (left) Auto focus hand switch (right) Fast start-up

Failure analysis

Future expandability

High efficiency





#### More than 20% improvement in contrast at high magnifications.

#### Confocal system U-CFU

This unit integrates confocal optics into the tilting trinocular tube and is compatible with the 0.18µm rule inspection. High-precision devices with multiple layers can be inspected with high resolving power and high contrast.





U-CFU combined with MX61 (left) Less than 0.2µm lines & spaces image (right)

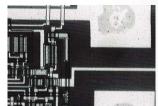


Suitable for observing silicon wafers, the inside of compound wafers, and the bonding section of wafer bump.

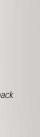
#### Near Infrared (IR) modules

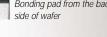
Compatible accessories include objectives which compensate for aberrations from the visible to near IR wavelength light and various other options, allowing comprehensive inspection of the bump wafer





Bonding pad from the back side of wafer







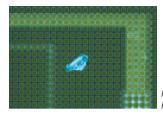
### FL

#### Suitable for judgement of resist residue.

#### Fluorescent modules

For fluorescence observation, a mirror unit can be added in the slider. U, B and G excitation mirror units are available; they are used for inspecting resist residue or organic LEDs





Fluorescence mirror units (left)
Particle on wafer (right)

# Transmitted Light Illumination

Indispensable for observing FPD or MEMS\* sensors.

#### Transmitted illumination modules MX-TILLA/MX-TILLB

There are two types of illumination modules: one for general purpose use and the other with high NA (Numerical Aperture). These transmitted illumination modules are provided to enable inspections for photomask and FPD. A polarizer is also equipped, allowing simple polarizing observations using transmitted light. \*Micro-Electro-Mechanical System







①Insertion slot for fiber light guide ②Filter slot ③Field Stop (F.S.) lever ④Centering holes (2) for F.S.

## I/F

Controling/obtaining information about microscope magnifications and aperture diaphragm.

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**OLYMPUS** 

An RS232C interface is equipped on the MX61/61L as standard, enabling various motorized parts of the microscope to be controlled via a PC. The observation conditions for several microscopes can be set in the same way: this makes it possible to establish such

conditions on a uniform basis among several PCs; to replicate particular environmental conditions of use.



# Motorized Stage

Specific observation points on the wafer can be programmed, reducing tact time.

### Motorized stage (MS200)

This stage is used when the MX61/61L is used in combination with wafer loader AL110. This enables complete surface inspections of a 200mm wafer, with specific inspection points quickly detected and examined according to preset programs.







### The MX51 Effect: More Efficient Inspections Throughout Industry.



Streamlined operation for faster, more comprehensive results

## Agile stage movement and coarse/fine movement interchange.

Two stage sizes are available, 150mm and 100mm. The 150mm stage has a built-in clutch lever, which enables quick location of specimens on the stage without diverting the operator's view, allowing quick, easy inspections.

## Repositioned optical controls for smoother performance.

Controls for focusing and light intensity adjustment are placed closer together, so that both can be operated with one and the same hand.



# Anti-static treatment prevents dust contaminating the sample.

The frame and 6-inch stage are coated to prevent static build-up.

\* Use special metal plate.

# SEMI S2/S8 compliance enhances safety and ergonomics.

The convenience of front operation is one of the Olympus' key design concepts, complemented by compliance with international industry standards to guarantee superior reliability.

# Motorized revolving nosepiece enables direct exchange of objectives for higher efficiency.

In addition to the standard nosepiece, the MX51 can be equipped with a range of motorized nosepieces. An external handset allows direct selection of the desired objective. The MX51 also offers a centerable, motorized nosepiece for accurate

positioning for easy observation at high magnifications.



### Practical versatility: the MX51 is ideal for many different kinds of inspections

## Latest UIS optics maximize detection of even tiny defects.

Fast, accurate detection of defects, and hence fewer check failures, are ensured by the MX51's enhanced brightfield/darkfield observation capabilities, which deliver approximately 4\* times greater detection sensitivity than previous model. Outstanding accuracy in observation of small diameter wafers such as those used in today's smaller sensors and many other high-performance electronic devices.

\*In the recommended set of objective lens and illumination tube

### Offers multiple observation methods from visible to fluorescence and near-IR.

The standard illuminator (BX-RLA2) complies with near IR observation, as well as offering brightfield, darkfield, Nomarski DIC and simple polarizing observations. A universal illuminator (BX-URA2) is also available for fluorescence observation.

#### Transmitted light observation.

The combination of a transmitted illumination unit with the 150mm stage enables transmitted light brightfield observation of samples up to 2mm thick, with an illumination range of 100X100mm. The slim-profiled illumination unit is designed for minimal effect on the stage operation and is useful for observations of samples such as MEMS (Micro Electronics Mechanical Systems)

sensors and other optical/optronic components.



### Intermediate attachment raises objectives to accommodate thick samples.

The standard maximum sample thickness is 30mm. Insert the intermediate attachment to

accommodate thicker samples.



### Expandability: adding extra functions at minimal cost

# Combine with wafers loaders to increase work efficiency.

Use of the AL110-6 series wafer loaders, which accept wafers up to 150mm, offers front- and back-macro inspection and microscope inspection without the operator handling the wafers.



# Confocal module for high-resolution, highcontrast observations.

The confocal module (U-CFU) employs an original disk scanning method to deliver high-contrast, high-resolution observation images. This allows inspection of multi-layered electronic devices.

## Digital imaging with excellent cost performance.

A wide range of cost-effective Olympus digital cameras can be added to the MX51.

Additionally, adapters allow the use of digital or video cameras currently in use.



DP12 configuration

## Accepts many high-quality BX2M accessories.

A wide range of the highly-regarded BX2M series accessories can be used, including a tilting observation tube, motorized illuminator, various lamp housings, motorized revolving nosepieces, mirror units, prisms, filters and intermediate attachments.

### **Accessories**

#### Observation tubes



①MX-SWETTR Super widefield erect image tilting trinocular observation tube ②U-TR30-2 Trinocular tube ③U-SWTR-3 Super widefield trinocular tube ④U-ETBI Ergonomical binocular tube ⑤U-BI30-2 Binocular tube ⑥U-ETR-3 Erect image trinocular tubes

### Refrected light illuminators for MX51



- 1) BX-URA2 Universal reflected light illuminator
- 2BX-RLAA Motorized BF/DF reflected light illuminator
- 3BX-RLA2 Reflected light illuminator for BF/DF
- (4) **BX-KMA** Reflected light illuminator for BF (U-LS30-4 30W lamp socket included)

### Revolving nosepieces for MX51



- ①U-D7RE Septuple revolving nosepiece with slider slot for DIC
- **②U-D6BDRE** Sextuple BD revolving nosepiece with slider slot for DIC
- **3U-P5BDRE** Centerable quintuple BD revolving nosepiece with slider slot for DIC
- (4)U-D6RE Sextuple revolving nosepiece with slider slot for DIC
- **⑤U-D5BDRE** Quintuple BD revolving nosepiece with slider slot for DIC

### Motorized revolving nosepeices



①U-D6REMC Motorized sextuple revolving nosepiece with slider slot for DIC ②U-D5BDREMC Motorized quintuple BD revolving nosepiece with slider slot for DIC ③U-P5REMC Motorized centerable quintuple revolving nosepiece with slider slot for DIC

### Lamphousings



- ①U-LH100HG 100W mercury lamphousing
- **②U-LH100HGAPO** 100W mercury apo lamphousing
- ③U-LH100-3/U-LH100L-3 100W halogen lamphousing
- **4U-LH75XEAPO** 75W xenon apo lamphousing

### Stage accessories for MX51



①U-SIC4R2/L2 Right/left hand control large-size stages (should be combined with stage adapter MX-STAD, photo shown is U-SIC4R2) ②BH3-SP66 Stage glass plate ③BH3-SP6 6"stage plate ④BH3-WHP6 6" stage plate (Can be combined with BH2-WHR43/54/65) ⑤U-MSSP4 Stage plate ⑥U-WHP2 Plate (Can be combined with BH2-WHR43 for U-SIC4R2/L2) ⑦BH2-WHR43 4"-3" rotatable wafer holder ⑧BH2-WHR54 5"-4" rotatable wafer holder

### Please feel free to contact Olympus right away in the event of any new need or unexpected problem. We will be happy to help you find the most effective solution.

The semiconductor industry is exceptionally dynamic and fast-moving, constantly facing new issues and adapting to new advances. Olympus has wide experience of the challenges that result, and the kinds of solutions that different users need.

We stand with our customers, sharing ideas and solutions as an energetic, active and effective development partner.

— Your Vision, Our Future —

1990

1994

1996

1998

1999

2002

2005



**Beltless loading** Wafer loader / AL-1BL8



Confocal unit Real-time confocal microscope / MX50-CF



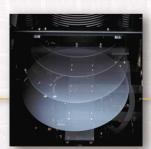
Front micro/macro and back macro inspection

Wafer loader / AL100 series

Super widefield tilting observation tube for the motorized stage Semiconductor inspection

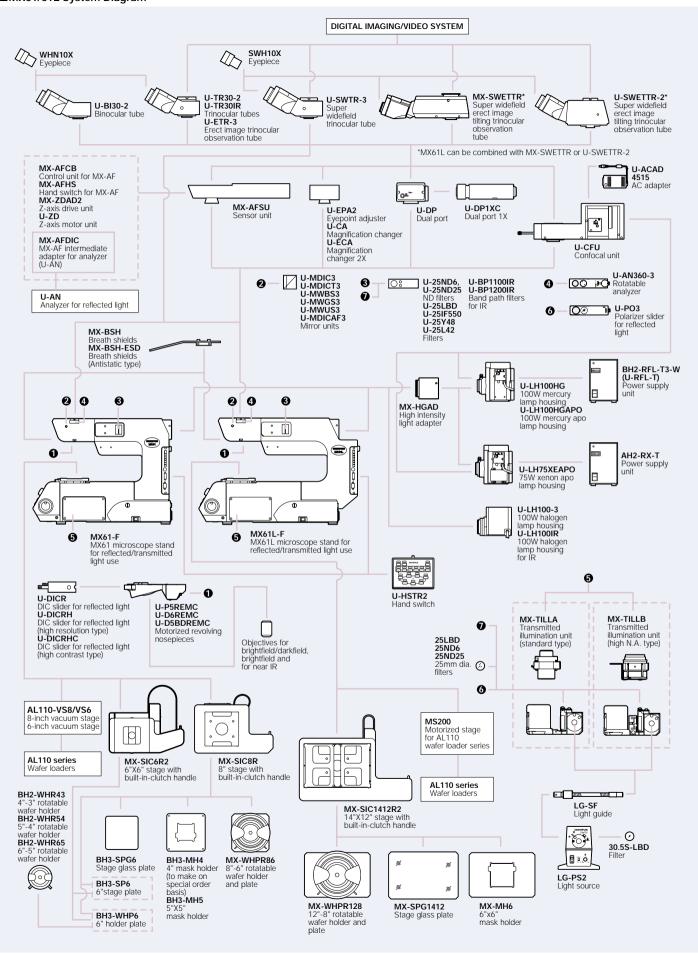
microscope / MX80

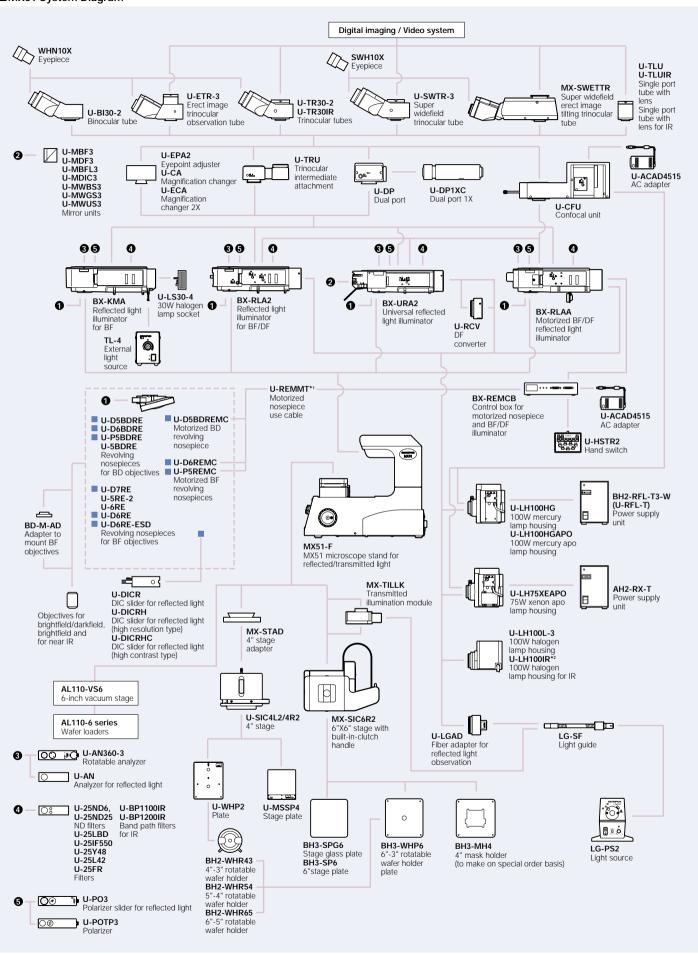
Confocal unit Confocal unit / U-CFU



Non-contact centering Wafer loader / AL110 series

#### ■MX61/61L System Diagram





### ■MX61/MX61L specifications

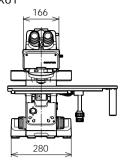
Model	MX61	MX61L				
Optics	UIS optics (infinity-corrected system)	UIS optics (infinity-corrected system)				
Microscope stand	Reflected light illumination (F.N. 26.5)  12V, 100W halogen lamp (pre-centering type)  Brightfield/darkfield mirror plus 1 cube (option), exchange method  Built-in motorized aperture diaphragm  (Pre-setting for each objective, automatically open for darkfield observation)					
	Transmitted light illumination* (F.N. 26.5)  *When transmitted illumination unit MX-TILLA or MX-TILLB is combined.  Illumination by light source LG-PS2 and light guide LG-SF (12V,100W halogen lamp) or their equivalent.  •MX-TILLA: condenser (N.A.0.5), with aperture stop  •MX-TILLB: condenser (N.A.0.6), with aperture stop and field stop					
	Observation methods  ①Reflected light brightfield ②Reflected light darkfield ③Reflected light Nomarski DIC ④Reflected light simple polarizing ⑤Reflected light fluorescence ⑥Reflected light IR ①Transmitted light brightfield ⑧Transmitted light simple polarizing *Separate (optional) cubes are required for ③, ④ and ⑤. **① and ⑩ require combination with a transmitted illumination unit.					
Observation tube	Super widefield erect image tilting trinocular tube (F.N.26.5): MX-SWETTR Others: Super widefield trinocular tube/Widefield binocular tube	Super widefield erect image tilting trinocular tube (F.N.26.5): MX-SWETTR or U-SWETTR (MX-SWETTR is equipped for MX61L as standard.)				
Revolving nosepiece	Motorized quintuple BD revolving nosepiece with slider slot for Motorized centerable quintuple revolving nosepiece with slider states.	Motorized sextuple revolving nosepiece with slider slot for DIC: U-D6REMC Motorized quintuple BD revolving nosepiece with slider slot for DIC: U-D5BDREMC Motorized centerable quintuple revolving nosepiece with slider slot for DIC: U-P5REMC Forward rotation by objective exchange button on the front panel of microscope, or directly by hand switch U-HSTR2 (user designation)				
Stage	MX-SIC8R 8"x8" stage Stroke: 210x210mm (Transmitted light illumination area: 189x189mm) MX-SIC6A 6"x6" stage Stroke: 158x158mm (Reflected light use only)	MX-SIC1412R2 14"x12" stage Stroke: 356x305mm (Transmitted light illumination area: 356x284mm) combination with MX-TILLB				
	Roller guide slide mechanism, belt drive system (no rack), grip clutch function (belt drive disengagement system)					
Power consumption		Built-in reflected light source body 100-120/220-240V-1.9/0.9A 50/60Hz, Transmitted light source (LG-PS2) 100-120/220-240V-3.0/1.8A 50/60Hz				
Dimensions/weight	Dimensions: approx. 509(W) x 843(D) x 507(H)mm Weight: approx. 40kg (microscope stand only approx. 27kg)	Dimensions: approx. 710(W) x 843(D) x 507(H)mm Weight: approx. 51kg (microscope stand only approx. 31kg)				

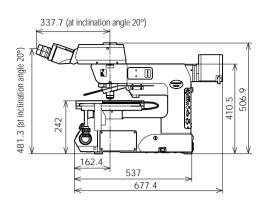
### ■MX51 specifications

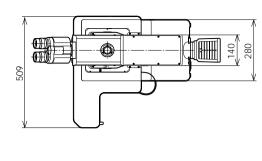
	Concations						
Optics		UIS Optics (infinity-corrected system)					
Microscope stand		2-guide rack and pinion method Coarse and fine co-axial Z-axis control stroke 32mm (2mm upper and 30mm below from the focal plane) The same stroke 15mm (combination with transmitted illumination) Stroke per rotation of fine Z-axis control 0.1 mm (1 unit 1µm) Coarse handle torque adjustment Coarse handle upper limit lever					
Illumination		BX-KMA Brightfield illuminatior	BX-RLA2 Brightfield/Darkfield illuminator		BX-URA2 Universal Fluoresccence illuminator		
	Contrast changeover method	_	BF-DF slide method		Mirror (Max. up to 6) turret motheod		
	Applicable observation mode  ① Brightfield ② Normaski DIC ③ Polarized light		② Da ③ Norm ④ Polar	ghtfield rkfield naski DIC ized light IR	Brightfield     Darkfield     Normaski DIC     Polarized light     Fluorescence		
Lamphousing		6V30W Halogen Lamp socket: U-LS30-4 Transformer: TL-4	12V100W Halogen Lamphouse: U-LH100L-3 Power supply is integrated in MX51		Mercury lamp house: U-LH100HGAPO External power supply BH2-RFL-T3 needed		
Transmitted illumination		Brightfield MX-TILLK combined with fiber light guide illumination (configured with MX-SIC6R2)					
Power supply unit		_	Rated voltage: 100-120/220 Continuous ligh				
Observation tube		U-BI30-2 Widefield binocular, U-TR30-2 Widefield trinocular, U-ETR3 Widefield erect image trinocular (F.N. 22) U-SWTR Superwidefield trinocular, MX-SWETTR Superwidefield erect image tilting trinocular (F.N. 26.5)					
Revolving nosepiece		U-5RE-2, U-6RE U-D5BDRE, U-D6BDRE, U-P5BDRE (with slider slot for DIC Prism)					
Stage		U-SIC4R2/SIC4L2 Coaxial right/left-hand control 4"X4" stage M		MX-SIC6R2 Coa	MX-SIC6R2 Coaxial right/left-hand control 6"X6" stage		
		Drive method: rack and pinion method Y axis stopper: lever method		Drive method: Belt method Stroke: 158(X) X158 (Y) mm Clutch method: 2 clutch plates (Built-in-clutch ON/OFF handle) Holder dimensions: 200 X 200mm Transmitted light area: 100 X 100mm			
Dimensions/weight Dimensions: Approx. 430(W) X 591(D) X 495(H)mm Weight: Approx. 26kg (Stand Approx. 11kg)					prox. 11kg)		

### ■Dimensions (unit: mm)

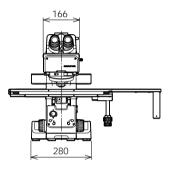
### MX61

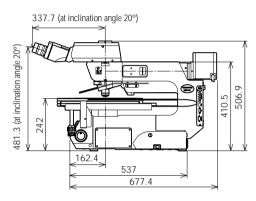


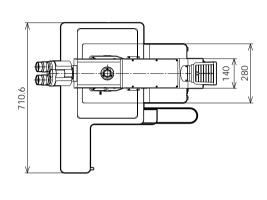




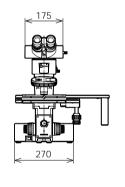
#### MX61L

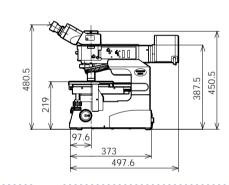


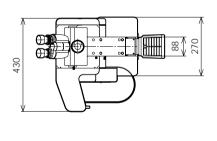




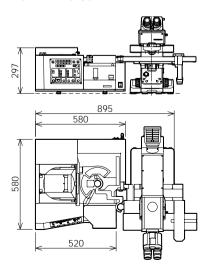
#### MX51



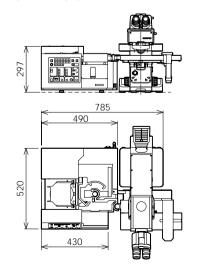




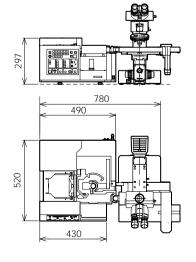
MX61+AL110-86



MX61+AL110-6



MX51+AL110-6



#### ■Objectives

■ Objectives									
Lens Optical character	Magnifi- cation	N.A.	W.D. (mm)	Cover glass thickness (mm)	Resolu- tion*² (µm)				
UMPLFL	5X 10X 20X 40X 50X 100X	0.15 0.30 0.46 0.75 0.80 0.95	20.0 10.1 3.1 0.63 0.66 0.31	 0 0 0	2.24 1.12 0.73 0.45 0.42 0.35				
UMPLFL-BD	5X 10X 20X 50X 100X	0.15 0.30 0.46 0.80 0.90	12.0 6.5 3.0 0.66 0.31		2.24 1.12 0.73 0.42 0.37				
UMPLFL-BDP	5X 10X 20X 50X 100X	0.15 0.25 0.40 0.75 0.90	12.0 6.5 3.0 0.66 0.31		2.24 1.34 0.84 0.45 0.37				
LMPLAPO	150X 250X	0.9 0.9	1.0 0.80	0	0.37 0.37				
LMPLAPO-BD	150X 250X	0.9 0.9	1.0 0.80	0	0.37 0.37				
LMPLFL	5X 10X 20X 50X 100X	0.13 0.25 0.40 0.50 0.80	22.5 21.0 12.0 10.6 3.4	 0 0 0	2.58 1.34 0.84 0.67 0.42				
LMPLFL-BD	5X 10X 20X 50X 100X	0.13 0.25 0.40 0.50 0.80	15.0 10.0 12.0 10.6 3.3	 0 0 0	2.58 1.34 0.84 0.67 0.42				
MPLAPO	20X 50X 100X 100XOil	0.60 0.95 0.95 1.40	0.90 0.30 0.35 0.1	0 0 0 0	0.56 0.35 0.35 0.24				
MPLAPO-BD	100X	0.9	0.31	0	0.37				
MPLFL-BD	50X 100X	0.8 0.9	1.0 1.0	_	0.42 0.37				
MPL*3	5X 10X 20X 50X 100X	0.10 0.25 0.40 0.75 0.90	19.6 10.6 1.3 0.38 0.21	 0 0 0	3.36 1.34 0.84 0.45 0.37				
MPL-BD*1*3	5X 10X 20X 50X 100X	0.10 0.25 0.40 0.75 0.90	12.0 7.0 1.3 0.38 0.21	 0 0 0	3.36 1.34 0.84 0.45 0.37				
SLMPL	20X 50X	0.35 0.45	21.0 15.0	0	0.58 0.75				
LCPLAPO	20X 50X	0.40 0.60	8.8 3.1	0/0.7/1.1 0/0.7/1.1	0.84 0.56				
LCPLFL-LCD	100X	0.80	0.95/ 1.1/ 1.143	0.6-1.2	0.42				
LMPL-IR	5XIR 10XIR 20XIR 50XIR 100XIR	0.10 0.25 0.40 0.55 0.80	20.0 18.5 8.1 6.0 3.4	_ _ _ _	_ _ _ _				
MPL-IR	100XIR	0.95	0.3	_	_				

<sup>\*1</sup> When MPL-BD objectives are used in combination writer MPL-BD objectives are used in Combination
with the U-LH100HGAPO/ULH75IXEAPO lamp housing (mercury/xenon socket) for darkfield
observation, illumination near the perimeter of the field of view may be slightly insufficient depending
on the specimen.

\*2 Resolving power calculated with the aperture diaphragm fully opened.

\*3 Up to F.N. 22.

### 200/300mm AUTOMATED SEMICONDUCTOR INSPECTION MICROSCOPE

### **MX80**

- •Microscope related operations are almost automated.
- •Observation conditions are programmable to get the optimal condition.
- •2 types of standard manual stage sselectable: 210x210mm and 356x305mm.
- •2 types of auto-focus frame and manual focus frame selectable.



•OLYMPUS CORPORATION obtains ISO9001/ISO14001.

Specifications are subject to change without any obligation on the part of the manufacturer.

